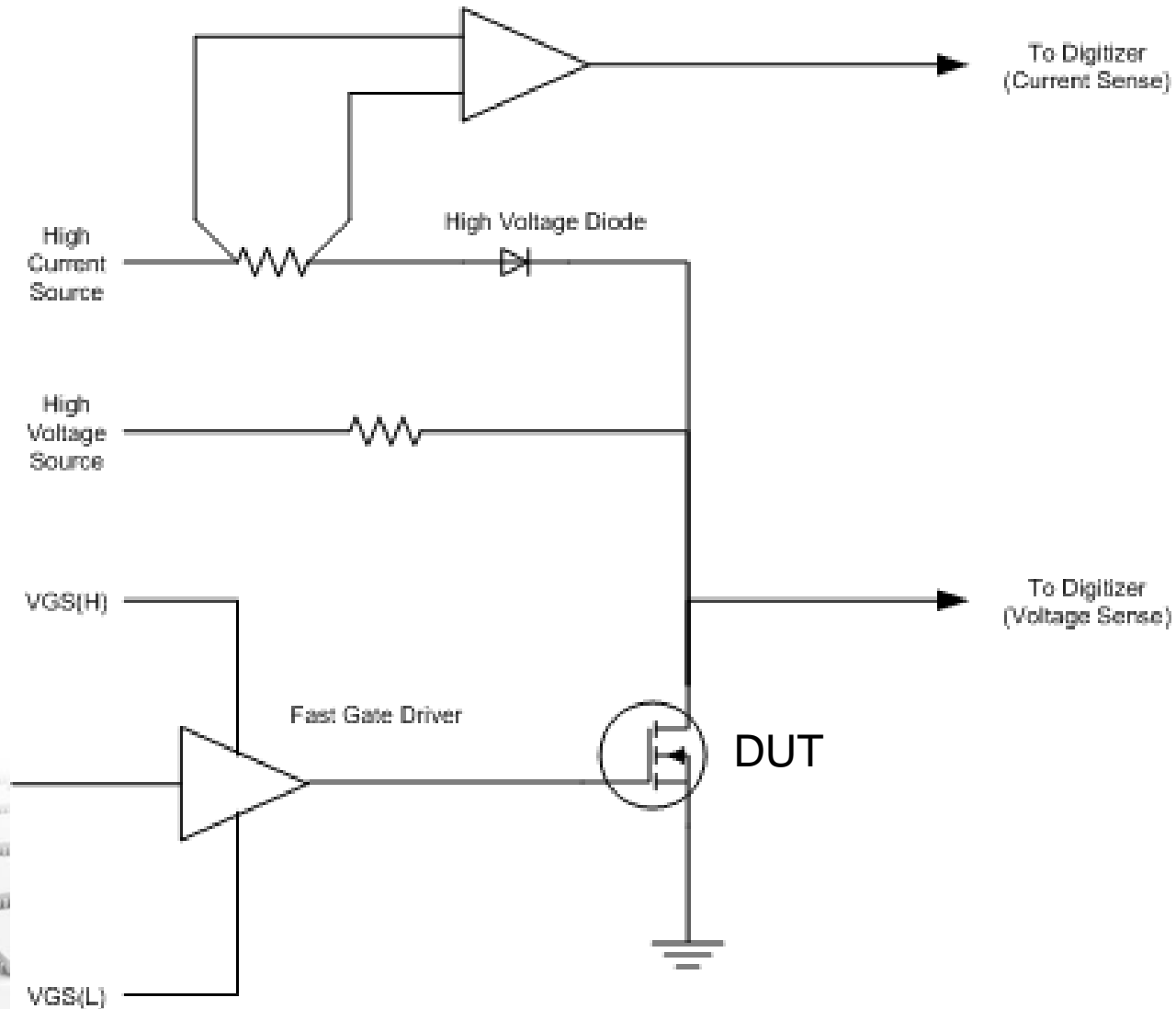


Dynamic Rdson Test: Key Requirements

- Fast, Single Shot Measurement for good Repeatability
- Test is required to detect areas of wafer with highest trapping
- Tester must tolerate bad DUT to avoid Probe Card failures
- Fast Switching Time from OFF to ON State (need $<1\mu\text{s}$)
- Fast Sampling to see Transients and Settling Time (need $>20\text{ MS/s}$)
- Vds Stress Voltage needs:
 - Controlled Rise Time (no Overshoot)
 - Current must be Limited
 - Accurate Monitoring of Voltage and Leakage Current
- $<1\mu\text{s}$ Measurement Delay after End Vstress and Start 2nd Rdson
 - Minimize Stray Capacitance and Inductance

COMPANY CONFIDENTIAL

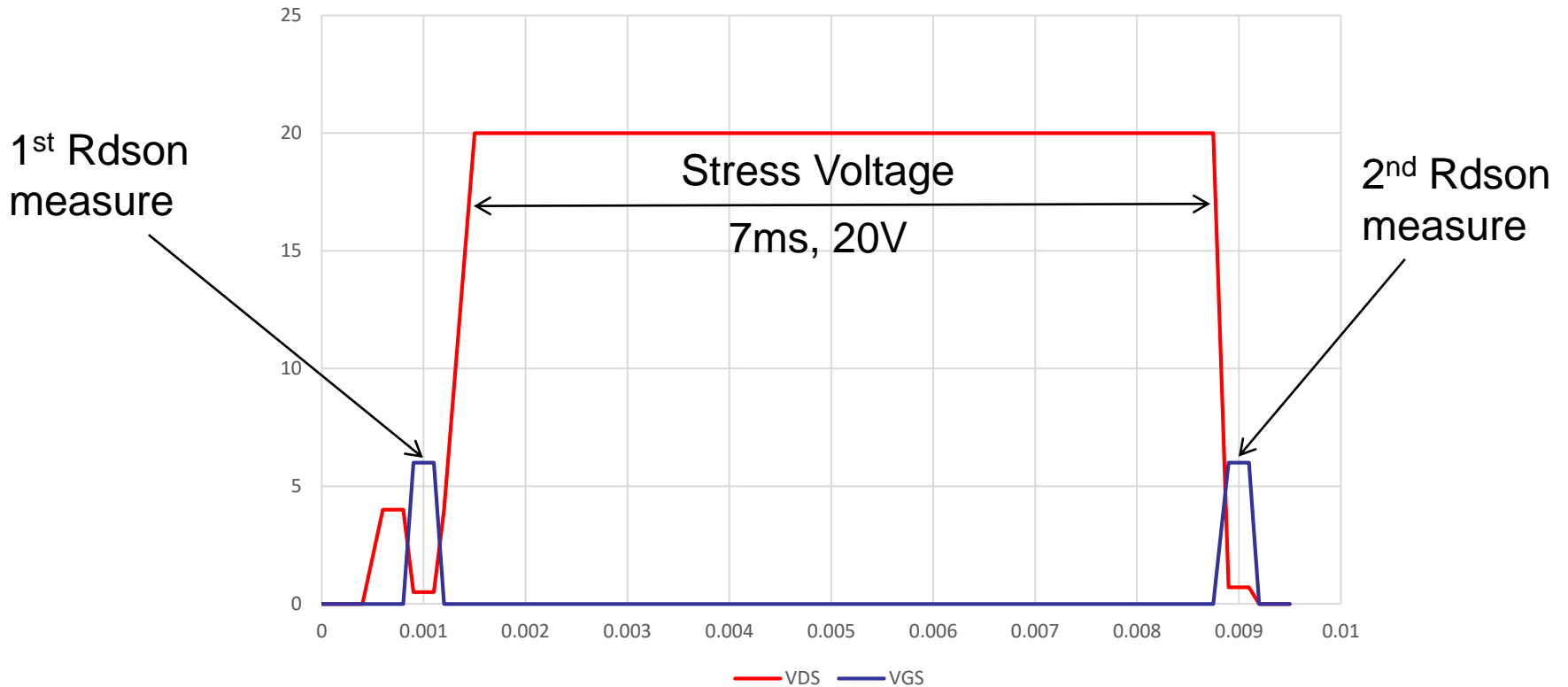
Dynamic Rdson Test Circuit



COMPANY CONFIDENTIAL

FOCUSED TEST, INC.

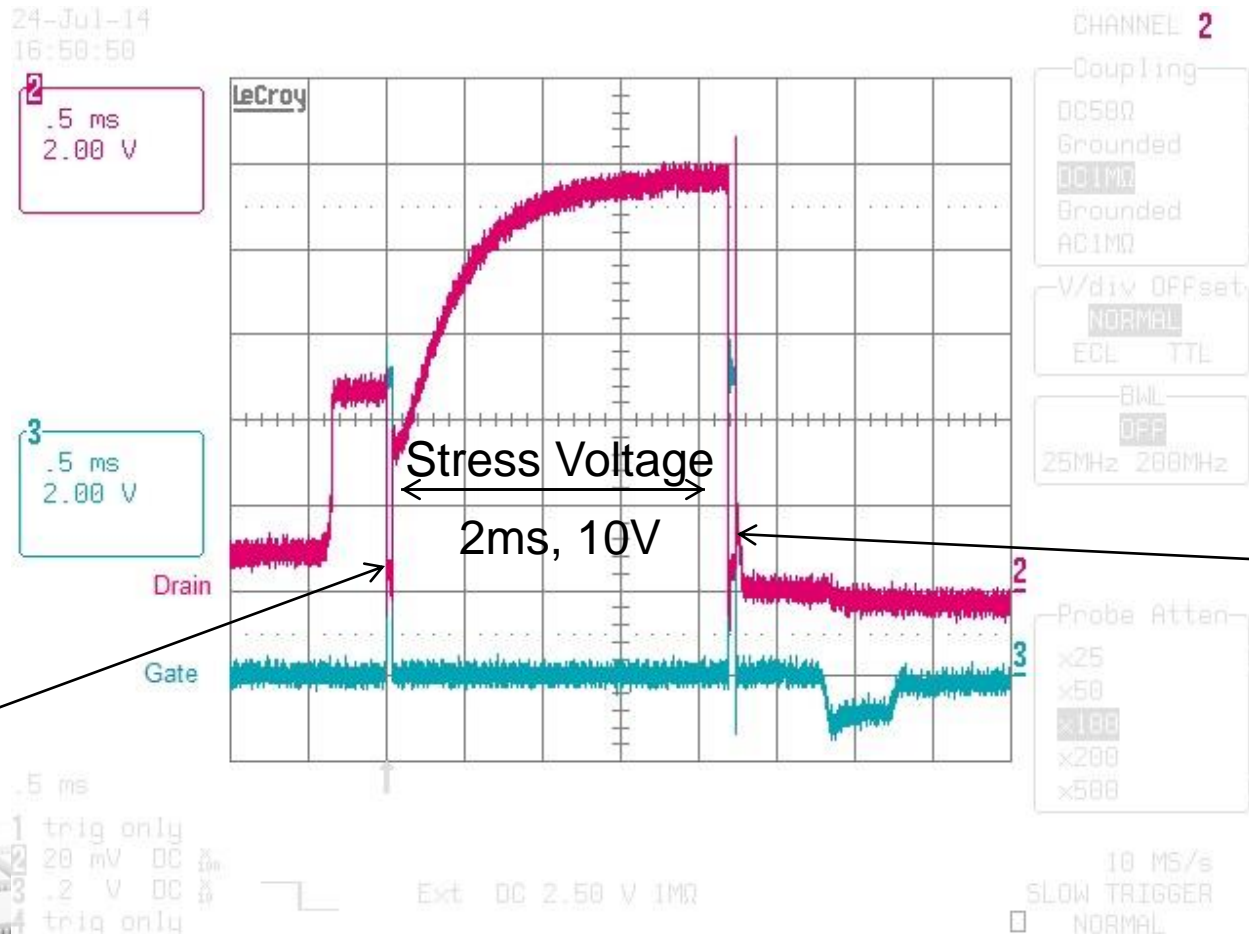
GaN Dynamic Rdson Test Method



COMPANY CONFIDENTIAL

GaN Dynamic Rdson Test Method

E-Mode Device



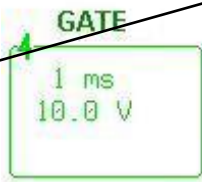
COMPANY CONFIDENTIAL

GaN Dynamic Rdson Test Method

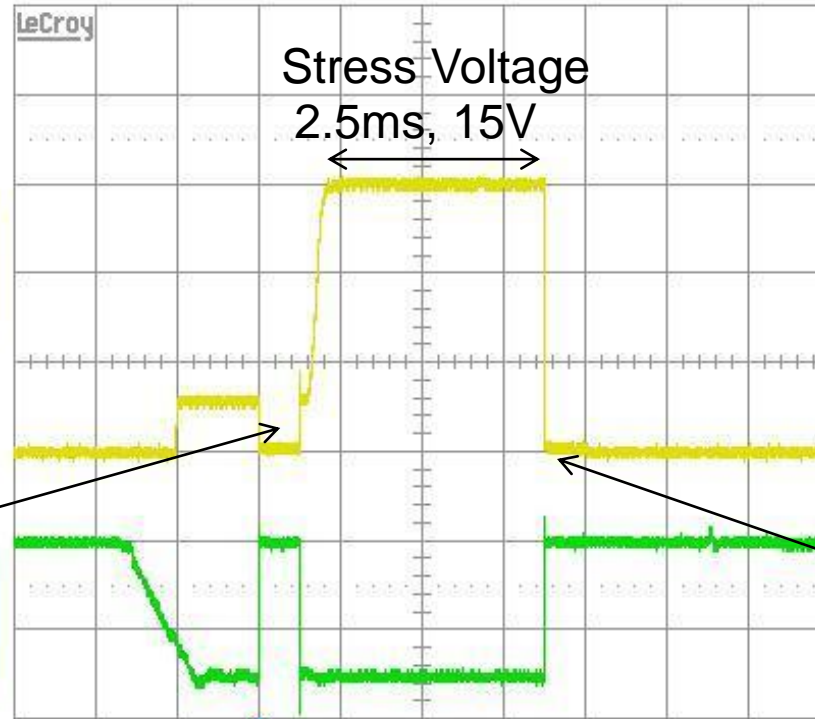
14-Oct-13
21:05:50

MEASURE

D-Mode
Device



1st Rdson
measure



- Cursors
- Parameters
- Pass / Fail
- Disk Failure Analysis

2nd Rdson
measure

1 ms
1 1 V DC X
2 trig only
3 trig only
4 1 V DC X

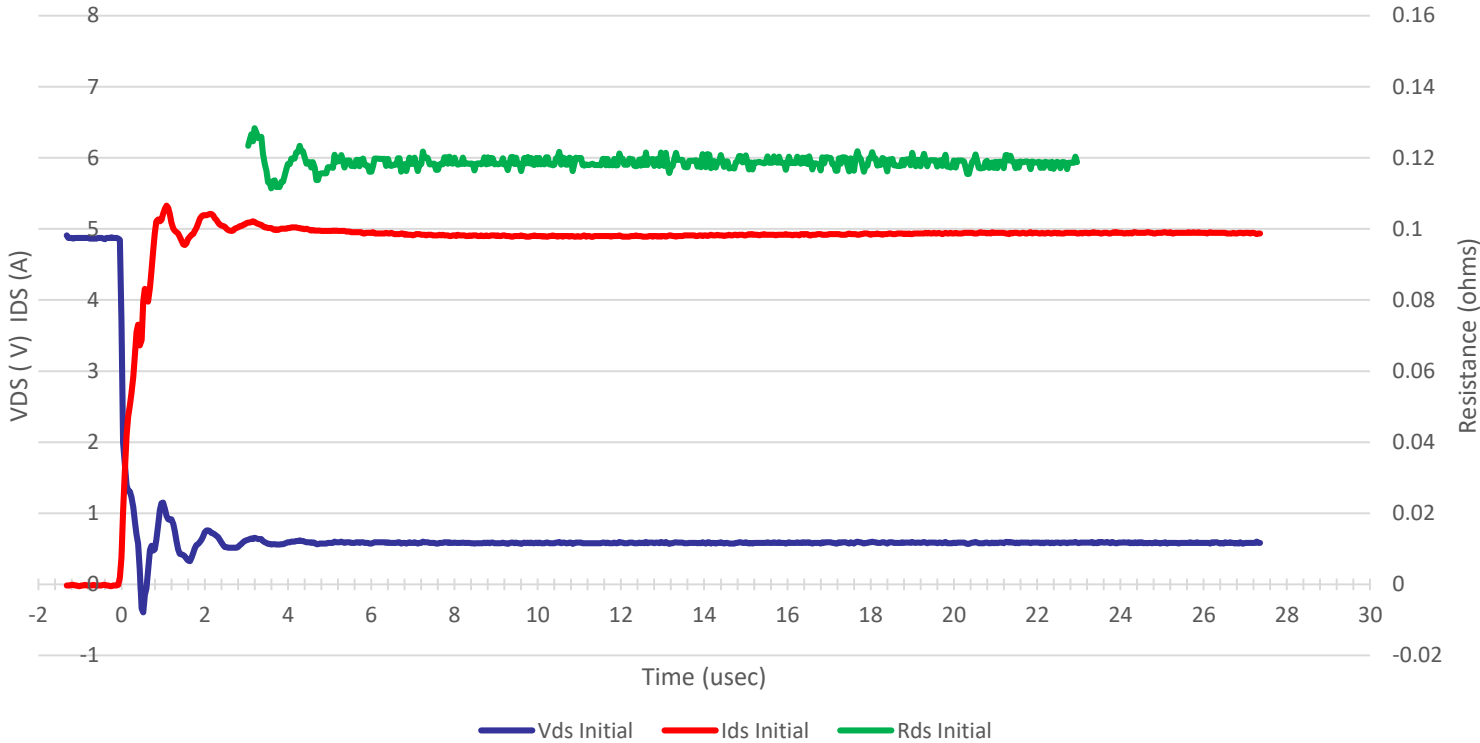
3 00 2.24 V

5 MS/s
SLOW TRIGGER
NORMAL

COMPANY CONFIDENTIAL

F FOCUSED TEST, INC.

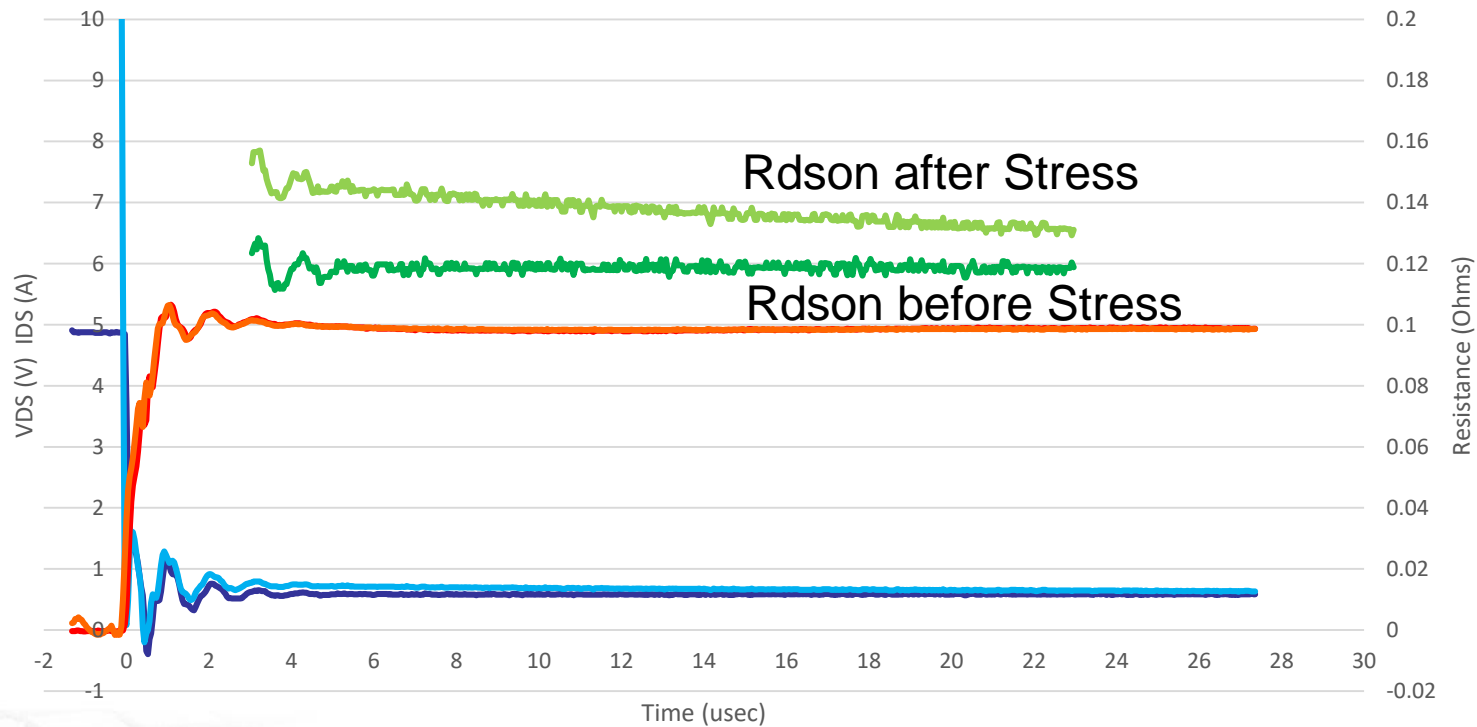
GaN Drdson Before Stress



COMPANY CONFIDENTIAL



GaN DRdson after Stress: 500V for 5ms

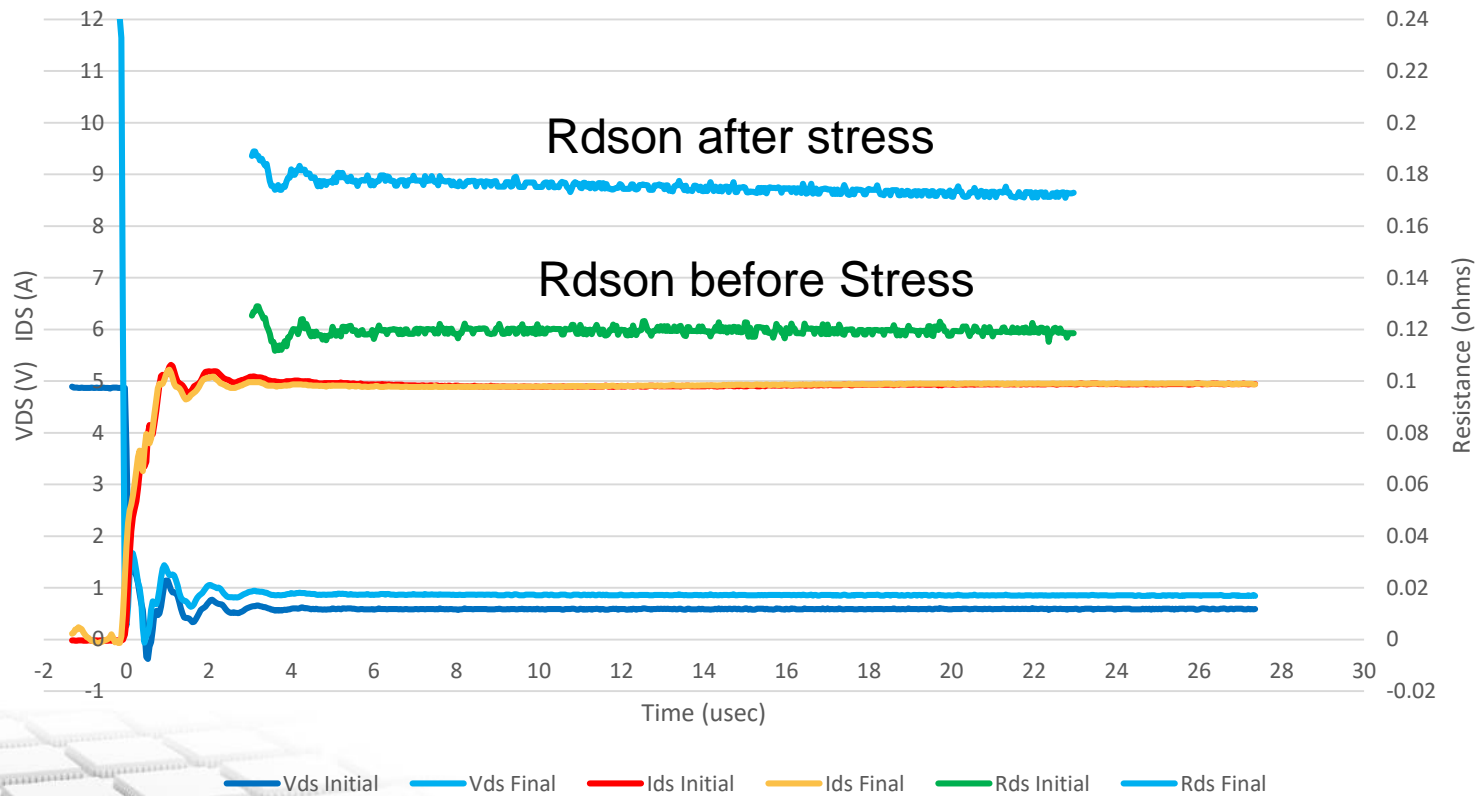


— Vds Initial — Vds Final — Ids Initial — Ids Final — Rds Initial — Rds Final

COMPANY CONFIDENTIAL

F FOCUSED TEST, INC.

GaN DRdson after Stress: 500V for 5s



COMPANY CONFIDENTIAL

FTI 1000 with Dynamic RDson Test Station



COMPANY CONFIDENTIAL

FOCUSED TEST, INC.

FAQ's

- Can Hard Switching be used?
 - Yes – add inductance in series with current sensor.
- Need to measure DRdson immediately after Stress to emulate real-life conditions
 - Agreed , but the worst case needs to be measured in a few μs after stress, which is effectively the same measurement as Dynamic Rdson.
- Why test 100% of devices in production test?
 - Trapping varies across the wafer, and so there is no other way to know if a specific die has higher Rdson
- What are minimum practical test times?
 - Measure time 10 μs (5 μs settling, 5 μs averaging), Stress Time 50 – 100 msec for wafer sort.
 - It is possible to test faster, maybe as low as 1 μs settling and < 10 msec stress, for packaged part test.

COMPANY CONFIDENTIAL

 **FOCUSED TEST, INC.**